



VIT

Vellore Institute of Technology

Slot: A2+TA2

SCHOOL OF ELECTRONICS ENGINEERING
Continuous Assessment Test – 1 Winter 2022-23 Semester
BECE201L – Electronic Materials and Devices

Max. Marks: 50

Duration: 90 min

Programme: B. Tech

Class Number: VL2022230504646

Faculty Members: Dr. Penchalaiah Palla

General Instructions: Answer All Questions

Silicon: $m^* = 0.26 m_0$, $N_C = 2.8 \times 10^{19} \text{ cm}^{-3}$, $N_V = 1.04 \times 10^{19} \text{ cm}^{-3}$, $n_i = 1.5 \times 10^{10} \text{ cm}^{-3}$, $E_g = 1.1 \text{ eV}$, Relative permittivity $\epsilon_r = 11.8$, $\mu_n = 1350 \text{ cm}^2/\text{V-s}$, $\mu_p = 480 \text{ cm}^2/\text{V-s}$. Other Constants: $kT = 0.026 \text{ eV}$ at 300K, Boltzmann's constant $k = 8.66 \times 10^{-5} \text{ eV/K}$, $t_0 = 8.854 \times 10^{-14} \text{ F/cm}$, $q = 1.6 \times 10^{-19} \text{ C}$, $m_0 = 9.1 \times 10^{-31} \text{ kg}$.

- 1 (a) Write a short note on various types of crystal defects and their significance [4]
 (b) Write the Miller Indices for the shown crystal Plane with all procedural steps [3]



- 2 (a) List the names of 3D crystal Bravais Lattice structures [3]
 (b) Derive an expression for DC electrical conductivity of a metal using Drude's theory [5]
 (c) A specimen of metal has 7.87×10^{28} free electrons per cubic meter. The mobility of electrons in the metal is $35.2 \text{ cm}^2/\text{V-s}$. (i) Compute the conductivity of the metal (ii) if an electric field of 30 V/cm is applied across the specimen, find the drift velocity of the free electrons and the current density. [5 M]

- 3 A hypothetical semiconductor, with bandgap of 2.7 eV, has $N_C = 10^{19} \text{ cm}^{-3}$, $N_V = 5 \times 10^{18} \text{ cm}^{-3}$. If the material is doped with 10^{17} cm^{-3} donors (fully ionized), calculate:
 (i) Intrinsic carrier concentrations at 300 K (ii) Carrier concentration of Majority carriers at 400 K
 (iii) Carrier concentration of Minority carriers at 500 K

- 4 An n-type Si wafer with donor concentration of 10^{16} cm^{-3} is available. In a region, p-type impurity of concentration $5 \times 10^{18} \text{ cm}^{-3}$ is doped uniformly. Compute the following: (i) Position of Fermi-level with respect to E_C and E_V in n-type and p-type regions respectively (ii) Sketch the model energy band diagram with proper labels (iii) Calculate the drift current for the applied field of 2.1 V/cm across the p-region area $10 \mu\text{m}^2$. [10]

- 5 An $E(k)$ plot is shown for a semiconductor. Answer the following questions with reference to the $E(k)$.

- (i) Is this a direct or indirect bandgap semiconductor?
- (ii) What is the bandgap of this semiconductor?
- (iii) Where is the largest effective mass for electrons, (point A or C)?
- (iv) Where is the negative effective mass for electrons, (point A, B, or C)?
- (v) What is the velocity of an electron at point D (positive, zero, or negative)?
- (vi) Compare the density-of-states in energy, D (E), at points A and C. Which one is larger?
- (vii) For common, cubic semiconductors, what is the shape of the constant energy surface near point A? (Spherical or ellipsoidal)
- (viii) For common, cubic semiconductors, what is the shape of the constant energy surface near point C? (Spherical or ellipsoidal)

